



RECEIVED
JUL 16 2003
TC 1700

1756
6/16/03
#81 Response

Dkt. 2271/50717-AY

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of : Hiroko IWASAKI

Serial No. : 09/836,144 Group Art Unit: 1756

Date Filed : April 17, 2001 Examiner: J. McPherson

For : OPTICAL DATA RECORDING MEDIUM AND MATERIAL FOR
HEAT-RESISTANT PROTECTION LAYER FOR THE SAME

1185 Avenue of the Americas
New York, N.Y. 10036

Commissioner for Patents
Washington, D.C. 20231

RESPONSE TO CLAIM RESTRICTION REQUIREMENT

This is a response to the Office Action dated June 10, 2003 requiring restriction of inventions under 35 U.S.C. 121. The office action indicates that applicant should elect one of the nitrides from claims 11-13. In response applicant elect with traverse the nitride disclosed in claim 12. *Silicon nitride*

The restriction requirement is traversed because it is believed that all of the claimed inventions are sufficiently related to each other to be examined in one patent application.

Respectfully submitted,

RICHARD F. JAWORSKI
Registration No. 33,515
Attorney for Applicant
Cooper & Dunham LLP
Tel.: (212) 278-0400

I hereby certify that this paper is being deposited this date with the U.S. Postal Service as first class mail addressed to: Commissioner of Patents and Trademarks, Washington, D.C. 20231.

Richard F. Jaworski
Reg. No. 33,515

Date

July 10, 2003